

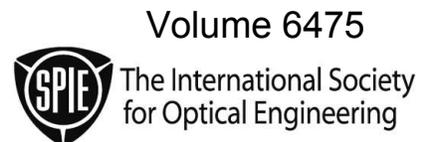
PROCEEDINGS OF SPIE

Integrated Optics: Devices, Materials, and Technologies XI

**Yakov Sidorin
Christoph A. Waechter**
Editors

**22–24 January 2007
San Jose, California, USA**

Sponsored and Published by
SPIE—The International Society for Optical Engineering



Proceedings of SPIE—The International Society for Optical Engineering, 9780819465887, v. 6475

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Author(s), "Title of Paper," in *Integrated Optics: Devices, Materials, and Technologies XI*, edited by Yakov Sidorin, Christoph A. Waechter, Proceedings of SPIE Vol. 6475 (SPIE, Bellingham, WA, 2007) Article CID Number.

ISSN 0277-786X
ISBN 9780819465887

Published by
SPIE—The International Society for Optical Engineering
P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone 1 360/676-3290 (Pacific Time) · Fax 1 360/647-1445
<http://www.spie.org>

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Printed in the United States of America.

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